FUTURE CMP PROCESSING REQUIREMENTS

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Linx Consulting
July 10, 2013
NCCAVS CMPUG @ Semicon West

SEE BEYOND THE HORIZON
1. We create knowledge and develop unique insights at the intersection of electronic thin film processes and the chemicals industry

2. We help our clients to succeed through our:

   - Experience in global electronics and advanced materials and thin film processing industries:
     - Semi
     - Packaging
     - Nano Technology
     - LCD
     - PV
     - Other

   - Experience in the global chemicals industry
   - Experience at Device Producers
   - Experience at OEMs
   - Global network and capabilities
   - Advanced modeling capabilities

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Industry Analysis Reports Offered

CMP Focused:
1. *CMP Technologies and Markets to the 11nm Node (5th edition)*
3. *CMP in TSV (2nd edition)*
4. *Wafer Polishing Technologies and Markets*

5. Advanced Thin Films for FEOL and BEOL Applications

6. Advanced Cleaning and Surface Preparation: Technologies and Markets

7. Advanced Patterning Forecasting

8. Chemicals and Materials for TSV Applications

9. *The Econometric Semiconductor Forecasting Service*

10. *Strategic Cost Model*
High Confidence Decision Support Services

PLANNING
Business Analysis
M&A / Due Diligence
Diversification / Expansion Planning

IDEAS TO MARKET
IP Development
Value Chain Analysis
Technology Assessment and Commercialization

SUPPLY CHAIN OPTIMIZATION
Quality System Auditing Or Pre-audit Assessment
Supplier Quality System Benchmarking
Quality/Product Management System Set-up Or Augmentation
Excursion Management

MARKETING & SALES
Market Analysis/monitoring
Market Forecasting and Modeling
Competitive Intelligence
Customer Perceptions

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SHORT TERM VISIBILITY

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Global Real GDP Growth: By Region

- US: below trend in 2013 and slips below total world growth
- Asia growth the highest, but region growth estimate has been shaved a little since Q1 2013 forecast
  - Japan a little stronger on new policies
  - China weaker after weak report for Q1 real GDP growth
- Eurozone recession continues through 2013, Europe overall flat

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Q2 2013 Semiconductor Forecast

MSI grows roughly 50% faster than Global Real GDP in 2013, better than past two years, with acceleration in 2014.
Semiconductor Area Forecast
Semiconductors (MSI)

<table>
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<tr>
<th>Q2 2013 Forecast (May 2013)</th>
<th>2013Q1</th>
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<th>2013Q3F</th>
<th>2013Q4F</th>
<th>2014Q1F</th>
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<td>4.8%</td>
<td>-6.7%</td>
<td>0.2%</td>
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TRENDS IN CMP SLURRIES AND PADS FOR NEW DEVICES AND WAFERS
Major Developments in CMP to Date

- Introduction of 300 mm wafers
- Introduction of direct STI
- Introduction of Copper CMP
- Introduction of Tungsten CMP
- Introduction of MG last and POP
- Introduction of finFET CMP

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Major Developments in CMP Going Forward

- **2013:** Introduction of III-V CMP and new B/S
- **2014:** Introduction of TSV
- **2015:** Introduction of Ge CMP
- **2016:** Introduction of finFET CMP
- **2017:** Introduction of 450mm wafer CMP

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Defectivity Requirements – Tools & Process

Control of the Tool
• The trend is towards extremely low downforce in the polishing process
• 1 to 2 psi is common at 14nm for oxide, nitride and poly (POP process) using ceria slurry
• Silicon FinFET processing also uses low downforce CMP

• RPMs on both the platen and head have to be optimized
  – Higher RPM increases the removal rate but leads to more abrasion on the surface
  – Therefore lower RPMs are required

Control of the Pad
• Pads
  – Grooves should be free from debris due to groove cutting
  – Pads should not have sharp edges
• Conditioning
  – Optimum conditioning of the pad is of paramount importance. Grit size of conditioners play an important role in defectivity control
Defectivity Requirements – Consumables

Control of the Slurries

• For 22nm and 14nm, the industry needs to have extremely tight control on the slurries and pad quality

• In advanced slurries, morphology of the slurry particles will be critical
  – No agglomerations and angular particles
  – Need mostly spherical particles and to minimize the number of edges

• Trend to low abrasives or abrasive free – 0.5% or lower solids content as the slurry formulation trend is to greater chemo effect than mechanical effect

• Selectivity requirements will prove challenging to slurries as selectivity is increased tuned as a key point of the overall process control

• Galvanic corrosion needs to be controlled in-situ – this is controlled by using the correct ingredients/formulations

• Advanced slurry formulations may utilize 10 to 15 distinct ingredients
New Materials are Increasing Rapidly

New Opportunities for Materials

The Quality Dilemma
1. New Materials are often found in / required for the most critical applications
2. New materials lead to new value chains
3. New value chains lead to new sources
4. New sources are usually unqualified

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Supply-Chain Optimization Background

- Market trend is to push supplier quality into the supply chain
- End customers (End-user) are pushing suppliers to avoid costly firefighting by pre-emptively qualifying the supply chain
- Some companies are developing collaborative programmes which are firewalled and confidential
- Others are demanding more information with an expectation of supplier transparency for the whole supply chain.
- Suppliers need to set up effective audit trails for all sub suppliers
- This may lie within the capability of large suppliers, but small and medium size suppliers may not have the expertise to develop acceptable supply change qualification systems
Future Quality Requirements

• Quality Improvement
  – Increasing number of metals and elements in CofA
    • 8 to 24 or full spectrum
  – Increased Sensitivity
    • ppm -> ppb -> ppt
    • Inorganic chemicals regularly specified at ppt levels
  – Function specifications becoming more specific
    • Resolution, DOF EL, line collapse, profile, adhesion, footing, toploss, LER, LWR
    • Selective etch rates
    • Polish rates, defectivity, dishing

• Service Improvement
  – Beyond SPC
  – Ship to stock qualification

• Sub-Supplier Monitoring
  – Materials component supply analysis
  – Materials fingerprinting
Incumbent Supplier Base is being Challenged

New material formulations being introduced
New suppliers bring innovation
Mature formulations used for new applications

Technology cycles are being compressed
New suppliers have a steep learning curve
End-users have limited process characterization resources

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The Entire Value Chain is Being Challenged

**End-Users**
- Need to have materials qualified
- Need to track more of the supply chain
- Need to control overheads
- Handling many more materials

**Sub-Suppliers**
- Original contracts did not call for stringent quality processes
- Do not sell directly to end-user — it is not our problem
- Do not know how to implement systems
- Need to understand appropriate levels of spending and scale to these operations

**Prime Suppliers**
- Being held accountable for sub-supplier systems
- Do not have capabilities to track activities at sub-suppliers
- Need to understand appropriate levels of spending and scale to these operations

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Supply Chain Optimization Challenge

- Companies at all levels in the value chain need to increase the levels of resourcing required to support the semiconductor industry.
  - Prime & sub-suppliers have multiple Tier 1 end users in the industry
  - End users have unique audit or pre-audit template required
  - Customer pre-audits and audits require significant resources to complete
  - Each process increases the depth and breadth of questions
  - Advanced process nodes require complete re-evaluation of established C of A

- Suppliers at all levels are struggling to meet expectations
  - New suppliers to the industry do not have the resources available
  - Older products have may have significant supply gaps but these will not be identified or closed to meet ramp cycles
  - Suppliers at all levels need to make new investments in quality systems and need guidance from a strategic materials supply chain organization.
What is Happening Today?

IC Manufacturers are making changes

- Focusing on formulation sub-suppliers
- Are evaluating strategic supplier readiness
- Imposed significant fines for quality manual violations
- Actively eliminating under performing suppliers

Suppliers need assistance to overcome barriers:

- Executive Sponsorship
  - Assignment of talent and resources for change
  - Commitment to attainment of quality goals
- Education
  - Understanding WHAT and WHY and HOW MUCH
- Involvement
  - All aspects of sales and operations are stakeholders for quality metrics
- Price
  - End users need to pay for the appropriate level of testing and production capabilities

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## Impact of Excursions

### Detection location

<table>
<thead>
<tr>
<th>IMPACT to:</th>
<th>Raws</th>
<th>Qualified Product</th>
<th>On Wafer</th>
<th>Packed Chips</th>
<th>Consumer Product</th>
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<tbody>
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<td><strong>Business</strong></td>
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<td>Operating capital</td>
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<td>Good Will</td>
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<td><strong>Technical</strong></td>
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<td>ID Root Cause</td>
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<td>Recurrence of Issue</td>
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Why Linx?

The advanced materials and tooling market is again evolving. New platform development is costly and risky. End-users are identifying new strategic partners and suppliers who they can rely on to help meet their business goals. Supply chain risk has been identified as a significant vulnerability. In response to this, FABs are rethinking strategic partnerships to focus on suppliers who have consistently met project deliverables and not slipped on manufacturing ramp schedules. We can help throughout this evolution.
Advanced Materials
Learning/Characterization

- Well controlled manufacturing at the prime supplier leads to product qualification
- Changed process at the sub-supplier changes end product performance
- Process audits identify areas of interest to be investigated during an excursion
- Sub-supplier process mapping is now expected during product development
- CofA are not sufficient for adv. materials
- GOAL: Eliminate Variation

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Summary

• Continued strong organic industry growth for balance of 300mm ramp out

• Many new CMP applications including:
  – 450mm wafers
  – TSV
  – FEOL – Ge and III-V
  – New barrier and seed

• Multiple new device types – MRAM and RRAM on the horizon to replace NAND and DRAM mean for new opportunities

• Supply Chain Management is key differentiator. The Impact of excursions grows with time
  – Quality and supply chain sources of deviation most be better understood
  – Companies with strong supply chain management are the most likely to expand at or better than the industry growth rate.